

Available online at www.sciencedirect.com

Tetrahedron Letters

Tetrahedron Letters 48 (2007) 3327–3330

Radical trifluoromethylation of ammonium enolates

Vitaliy Petrik and Dominique Cahard*

UMR 6014 CNRS de l'IRCOF, Université et INSA de Rouen, F-76821 Mont-Saint-Aignan Cedex, France

Received 16 February 2007; revised 14 March 2007; accepted 16 March 2007 Available online 21 March 2007

Abstract—The easy radical trifluoromethylation of a series of 1,3-dicarbonyl compounds with CF_3I is described. The reaction occurs in the presence of a nitrogen base and sodium dithionite in CH_3CN-H_2O solution. Additionally, we report a new access to ammonium triflinates.

© 2007 Elsevier Ltd. All rights reserved.

Fluorinated organic compounds are rare in nature whereas man-made fluorinated substances are extremely abundant and span nearly the whole fields of chemistry, including the life sciences and material chemistry.^{[1](#page-2-0)} Within organofluorine chemistry, the trifluoromethyl unit is an important structural moiety in diverse classes of organic molecules. Compounds containing the trifluoromethyl group are found in a wide variety of dyes, polymers, agrochemicals and pharmaceuticals. Often, the introduction of a trifluoromethyl unit in target products induced improved properties. In the life science industry, the changes in electronic, steric and physiological properties of fluorinated molecules increase their intrinsic activity, the biodisponibility and the metabolic stability. In the dye industry, it has been demonstrated that trifluoromethylated chromophores exhibit increased light fastness.[2](#page-2-0) Most of the liquid crystalline materials currently in use, for example in active matrix LCD, contain fluorine atoms; among them, trifluoromethylated liquid crystals fulfil the reliability require-ments for materials used in active matrix LCD.^{[3](#page-2-0)} As a consequence, there is a growing demand for trifluoromethylated building blocks that play a pivotal role in the synthesis of new fluorine-containing molecules with improved potency. Numerous synthons incorporating a CF_3 group attached to an aromatic ring are available from many suppliers. In contrast, other types of CF_3 synthons are less frequent; it includes aliphatic trifluoromethylated products, essentially stemming from trifluoroacetic acid, perfluoroalkyl chains, CF_3 -sulfoxide and

Keywords: Fluorine compounds; Trifluoromethylation; Radical reaction; 1,3-Dicarbonyl compounds; Triflinates.

0040-4039/\$ - see front matter © 2007 Elsevier Ltd. All rights reserved. doi:10.1016/j.tetlet.2007.03.097

 CF_3 -sulfonyl groups. These fluorinated building blocks can be used for conversion to more elaborated compounds. On the other hand, the synthetic access of trifluoromethyl-containing compounds is highly challenging by direct trifluoromethylation. The electrophilic trifluoromethylation, including radical processes, is a burgeoning topic that is highly important in organofluorine chemistry[.4](#page-2-0) Bromotrifluoromethane, Halon 1301, has been used for generation of trifluoromethyl radicals, but the Montreal protocol has required its complete phase-out. Replacement of freons and halons, in particular for application as fire-fighting agents in aircraft, led to the commercial production of trifluoromethyliodide which has been found to be non-ozone depleting and has an extremely low GWP value.

Trifluoromethyliodide has been used in the sulfinatodehalogenation reaction developed by Huang et al. to transfer the CF_3 radical to a variety of target molecules, which have electron-rich centres such as alkenes, alky-nes, arenes.^{[5](#page-3-0)} The sulfinatodehalogenation reaction with $CF₃I$ consists in a radical trifluoromethylation promoted by sodium dithionite or related reagent systems. Enol derivatives such as enamines,^{[6](#page-3-0)} enol acetates^{5a,b} and ketene dithioacetal^{[7](#page-3-0)} were also used as substrates, whereas silyl and germyl enol ethers were reacted with $CF₃$ radical generated by means of triethylborane.^{[8](#page-3-0)} Lithium enolates $4b,9$ and titanium ate enolates 10 of monocarbonyl compounds reacted with CF₃I in the presence of triethylborane as demonstrated by the groups of Iseki and Mikami. Paradoxically, 1,3-dicarbonyl compounds that are more easily enolisable have received poor attention. Uneyama et al. reported that electrochemically generated CF_3 radical from trifluoroacetic acid can be trapped with enolacetates and enols of 1,3-dicarbonyl

^{*} Corresponding author. E-mail: dominique.cahard@univ-rouen.fr

Scheme 1. Radical trifluoromethylation of β-keto esters.

compounds.[11](#page-3-0) We herein describe the easy radical trifluoromethylation of ammonium enolates of 1,3-dicarbonyl compounds with $CF₃I$ and sodium dithionite in $CH₃CN-H₂O$ solution.

We initially employed 1-oxo-indan-2-carboxylic acid methyl ester 1a as a model substrate to set up suitable reaction conditions for radical trifluoromethylation by means of CF3I in the presence of sodium dithionite as a free radical initiator (Scheme 1). The trifluoromethyl radical, being electron-deficient, is strongly electrophilic. It is generated from monoelectronic reduction of $CF₃I$ with sulfur dioxide radical anion. Different inorganic and organic bases were evaluated in aqueous acetonitrile, dimethylformamide or isopropanol. Representative results are listed in Table 1.

Of the inorganic bases used, cesium carbonate gave the best result in up to 65% yield. However, organic nitrogen bases were found to be superior in the radical trifluoromethylation since the bulky Hünig's base or DBU gave compound 2a in 81% and 84% yield, respectively.[12](#page-3-0) The amount of nitrogen base is also an important factor since 2 equiv are required for high conversion. One equivalent of base is needed to generate the ammonium enolate and the second equivalent probably contributes to the activation of $CF₃I$ by attractive interactions between the carbon-bound iodine in CF₃I and the electronegative nitrogen atom of the base.[13](#page-3-0) Optimal conditions were established for a solvent mixture acetonitrile/ water $(v/v = 3/2)$ at room temperature. Other polar solvents such as DMF or isopropanol gave lower reaction yields as for changing the volume ratio acetonitrile/

Table 1. Set-up of the conditions for radical trifluoromethylation

Substrate	Base	Solvent ^a	Product	Yield $^{\rm b}$ (%)
1a	K_2CO_3	CH_3CN/H_2O 2a		52
	$(4$ equiv)			
1a	Cs_2CO_3	CH_3CN/H_2O	2a	65
	$(4$ equiv)			
1a	Ouinuclidine	CH_3CN/H_2O	2a	41
	$(1$ equiv)			
1a	$Et3N$ (1 equiv)	$CH_3CN/H2O$	2a	37
1a	$Et3N$ (2 equiv)	CH_3CN/H_2O	2a	62
1a	$Et(i-Pr)_2N$	CH_3CN/H_2O	2a	81
	$(2$ equiv)			
1a	DBU (2 equiv)	CH ₃ CN/H ₂ O	2a	84
1a	DBU (2 equiv)	DMF/H ₂ O	2a	48
1 _b	DBU (4 equiv)	i -PrOH/H ₂ O	2 _b	21
1 _b	DBU (2 equiv)	DMF/H ₂ O	2 _b	51
1 _b	DBU (2 equiv)	CH_3CN/H_2O	2 _b	86

^a Solvent: $v/v = 3/2$.

b Isolated yields.

water. In the sulfinatodehalogenation reaction, a buffer is usually added in the medium to neutralise the sulfur dioxide and HI formed in the reaction. In our case, we found that addition of sodium hydrogenocarbonate did not improve the yield of the trifluoromethylation. The use of sodium hydroxymethylsulfinate (Rongalite) as an alternative radical source under anhydrous conditions in acetonitrile failed to produce the trifluoromethylated product; interestingly, we observed the hydroxymethylation of the 1,3-dicarbonyl compounds.

Having optimised the reaction conditions, we investigated the radical trifluoromethylation of cyclic and acyclic 1,3-dicarbonyl compounds $(\beta$ -keto esters and 1,3-diketones) using CF₃I, DBU as the base, $Na₂S₂O₄$ as the radical initiator and CH_3CN/H_2O as the solvent. Cyclic β -keto esters **1a–d** reacted with CF₃ radical generated from $Na₂S₂O₄$ and CF₃I to give the corresponding trifluoromethylated compounds 2a–d in high isolated yields. No significant diastereoselectivity was observed for product 2d bearing a chiral menthyl auxiliary. 2-Oxo-cyclopentanecarboxylic acid benzyl ester was used as a cyclic substrate having no aromatic-fused ring, but the trifluoromethylation occurred only in 28% yield. Replacing of the ester moiety with keto group as for 1,3-diketone 1e gave the trifluoromethylated compound 2e in 80% yield. In this case, reducing the amount of $Na₂S₂O₄$ to 50 mol % advantageously gave a quantitative reaction with an isolated 86% yield (Table 2).

Unfortunately, acyclic 1,3-dicarbonyl compounds provided only very low yields of trifluoromethylated products under the so far optimised reaction conditions for cyclic substrates. For investigation of acyclic 1,3-dicarbonyl compounds, we used 2-methyl-3-oxo-3-phenyl-

Table 2. Radical trifluoromethylation of β -dicarbonyl compounds

'n 1а-е	R	$+ CF3I$	DBU (2 equiv) Na ₂ S ₂ O ₄ (1 equiv) CH ₃ CN/H ₂ O (3:2), 1 h		CF ₃ 2а-е
Substrate	\boldsymbol{n}	R	Product	Conv ^a $(\%)$	Yield ^b $(\%)$
1a	1	OMe	2a	95	84
1 _b	2	OMe	2 _b	92	86
1c	1	OB _n	2c	93	84
1d	1	OMenthyl	2d	98	94
1e	2	Me	2e	90 $(99)^{\circ}$	$80(86)^{\circ}$

^a Conversion were determined by GC.

b Isolated yields.

^c Values in brackets are for reaction run with 50 mol % of Na₂S₂O₄.

Scheme 2. Radical trifluoromethylation of acyclic 1,3-dicarbonyl compounds.

propanoic acid alkyl esters 1f–h. The use of DBU alone or K_2CO_3 alone as a base did not allow the reaction to happen, whereas a combination of the two bases in the presence of a phase-transfer catalyst provided the trifluoromethylated products 2f–h in moderate yields (Scheme 2). Acyclic ammonium enolates generated from 1f–h are more soluble in water than their cyclic analogs and a phase-transfer catalyst is necessary for the transfer of enolates from water into organic phase. We found that 2 equiv of DBU and 1 equiv of K_2CO_3 with 10 mol % of tetrabutylammonium iodide were effective in the reaction.

A mechanism for the radical trifluoromethylation of 1,3 dicarbonyl compounds was proposed (Fig. 1). The reaction is a free radical process in which sulfinic radical anion SO_2 ⁻, existing in equilibrium with dithionite anion $S_2O_4^{2-}$, generate highly electrophilic trifluoromethyl radical from CF_3I by a SET process. The trifluoromethyl radical adds to the enolate (A) to give anion-radical intermediate (B), which reacts with another molecule of CF_3I to give trifluoromethylated anion (C) . After elimination of halogen, trifluoromethylated product (D) is formed.

Capture of the trifluoromethyl radical with sulfinic anion radical to give the trifluoromethanesulfinate (triflinate) was usually not observed in the trifluoromethylation of 1,3-dicarbonyl compounds. In few reactions, we detected by ¹⁹F NMR trace amount of trifluoromethanesulfinate at -88.3 ppm. A control experiment demonstrated that $CF₃I$ does not react with sodium dithionite alone; however, the addition of a nitrogen base (Et₃N, Et(i -Pr)₂N or DBU) enabled the formation of ammonium trifluoromethanesulfinates (Scheme 3). Here again, the nitrogen base intervenes to activate

$$
\begin{array}{ccc}\nCF_3I + Na_2S_2O_4 + R_3N & & & \xrightarrow{CH_3CN/H_2O (3:2)} & & & \xrightarrow{CF_3SO_2^-R_3NH^+} \\
& & & & \xrightarrow{rt, 1 h} & & & \\
& & & & 72\% \text{ with DBU} & & \\
& & & & 56\% \text{ with Et}(i-Pr)_2N \\
& & & & 32\% \text{ with Et}_3N\n\end{array}
$$

Scheme 3. Synthesis of ammonium trifluoromethanesulfinates.

CF3I. This reaction could be considered as an alternative of choice for the synthesis of organic soluble trifluoromethanesulfinates without use of Halon 1301[.14](#page-3-0)

In summary, we have described an unprecedented route to 2-trifluoromethyl-1,3-dicarbonyl compounds by radical trifluoromethylation with $CF₃I$ initiated by sodium dithionite. The use of $CF₃I$ is more atom economical than the use of Umemoto's reagents^{[15](#page-3-0)} and the reaction is experimentally very simple. Additionally, we have discovered a new synthesis of ammonium triflinates using $CF₃I$ instead of $CF₃Br$. The scope and limitations of the radical trifluoromethylation is underway in our laboratory.

Acknowledgment

The authors thank the 'Région Haute-Normandie' for a postdoctoral grant to Dr. V. Petrik.

References and notes

- 1. (a) Kirsch, P. Modern Fluoroorganic Chemistry; Wiley-VCH: Weinheim, 2004; (b) Chambers, R. D. Fluorine in Organic Chemistry; Blackwell: Oxford, 2004; (c) Fluorine in the Life Science Industrie. In Chimia 2004, 3, 92–162.
- 2. Banks, R. E. Preparation, Properties, and Industrial Applications of Organofluorine Compounds; Ellis Horwood Ltd, 1982.
- 3. (a) Kirsch, P. Angew. Chem., Int. Ed. 2000, 39, 4216–4235; (b) Hiyama, T.; Kusumoto, T.; Matsutani, H. Synthetic Aspects of Fluorine-Containing Chiral Liquid Crystals. In Asymmetric Fluoroorganic Chemistry. Synthesis, Applications, and Future Directions; Ramachandran, P. V., Ed.; American Chemical Society: Washington, 2000; 746, pp 226–238.
- 4. (a) Ma, J.-A.; Cahard, D. J. Org. Chem. 2003, 68, 8726– 8729; (b) Mikami, K.; Itoh, Y. The Chem. Rec. 2006, 6, 1– 11; (c) Kieltsch, I.; Eisenberger, P.; Togni, A. Angew. Chem., Int. Ed. 2007, 46, 754–757.

Figure 1. Proposed mechanism for the formation of 2-trifluoromethyl-1,3-dicarbonyl compounds by radical trifluoromethylation.

- 5. (a) Huang, W.-Y.; Wu, F.-H. Israel J. Chem. 1999, 39, 167–170; (b) Huang, W.-Y. J. Fluorine Chem. 1992, 58, 1– 8; (c) Liu, J.-T.; Sui, G.-D.; Chen, G.; Huang, W.-Y. J. Fluorine Chem. 1999, 93, 49–51; (d) Huang, W.-Y.; Zhang, H.-Z. J. Fluorine Chem. 1990, 50, 133–140; (e) Huang, W.-Y.; Lu, L.; Zhang, Y.-F. Chin. J. Chem. 1990, 8, 350-354.
- 6. (a) Cantacuzene, D.; Dorme, R. Tetrahedron Lett. 1975, 25, 2031–2034; (b) Cantacuzene, D.; Wakselman, C.; Dorme, R. J. Chem. Soc., Perkin Trans. 1 1977, 1365– 1371; (c) Kitazume, T.; Ishikawa, N. J. Am. Chem. Soc. 1985, 107, 5186–5191.
- 7. (a) Foulard, G.; Brigaud, T.; Portella, C. J. Org. Chem. 1997, 62, 9107–9113; (b) Foulard, G.; Brigaud, T.; Portella, C. J. Fluorine Chem. 1998, 91, 179–183.
- 8. (a) Miura, K.; Takeyama, Y.; Oshima, K.; Utimoto, K. Bull. Chem. Soc Jpn. 1991, 64, 1542-1553; (b) Miura, K.; Taniguchi, M.; Nozaki, K.; Oshima, K.; Utimoto, K. Tetrahedron Lett. 1990, 31, 6391–6394; (c) Itoh, Y.; Mikami, K. Tetrahedron 2006, 62, 7199–7203; (d) Mikami, K.; Tomita, Y.; Ichikawa, Y.; Amikura, K.; Itoh, Y. Org. Lett. 2006, 8, 4671-4673.
- 9. (a) Iseki, K.; Nagai, T.; Kobayashi, Y. Tetrahedron: Asymmetry 1994, 5, 961–974; (b) Iseki, K.; Nagai, T.; Kobayashi, Y. Tetrahedron Lett. 1993, 34, 2169–2170; (c) Itoh, Y.; Mikami, K. Org. Lett. 2005, 7, 4883–4885.
- 10. (a) Itoh, Y.; Mikami, K. Org. Lett. 2005, 7, 649–651; (b) Itoh, Y.; Mikami, K. J. Fluorine Chem. 2006, 127, 539– 544; (c) Itoh, Y.; Houk, K. N.; Mikami, K. J. Org. Chem. 2006, 71, 8918–8925.
- 11. Uneyama, K.; Ueda, K. Chem. Lett. 1988, 853–854.
- 12. Representative procedure of trifluoromethylation of bketo ester 1b. To a two-neck flask equipped with septum and magnetic stirrer were added 1b (0.53 mmol, 108.2 mg), DBU (1.06 mmol, 161.4 mg) and $CH₃CN$ (3 mL). The solution was stirred 15 min at room temperature and then was cooled to -30 °C and CF₃I (3 equiv, 588 mg) was added under vacuum via a syringe. A solution of sodium dithionite (0.53 mmol, 92.3 mg) in $2 \text{ mL of H}_2\text{O}$ was added and the mixture was warmed to room temperature and stirred for 1 h. The end of reaction was monitored by TLC (hexane/ethyl acetate $= 8/1$). The reaction mixture was diluted with 10 mL water and extracted with CH_2Cl_2 $(3 \times 10 \text{ mL})$. The organic layer was dried over MgSO₄ and evaporated under vacuum. The residue was purified by column chromatography to give compound 2b in 86% yield. ¹H NMR (300 MHz, CDCl₃) δ 2.35–2.45 (m, 1H), 2.74–2.81 (m, 1H), 2.93–2.97 (m, 2H), 3.70 (s, 3H), 7.17– 7.19 (m, 1H), 7.26–7.33 (m, 1H), 7.44–7.53 (m, 1H), 8.05 (d, $J = 7.9$ Hz, 1H); ¹³C NMR (75 MHz, CDCl₃) δ 25.4, 28.1, 54.1, 62.4 (q, $J_{\text{C-F}} = 24.6 \text{ Hz}$), 124.2 (q, $J_{\text{C-F}} =$ 282.5 Hz, CF₃), 127.7, 128.9, 129.1, 131.8, 134.7, 142.5, 166.2, 187.4; ¹⁹F NMR (282 MHz, CDCl₃ + CFCl₃) δ -67.94 (s, CF₃); MS (EI) m/z : 272 (M⁺).
- 13. Messina, M. T.; Metrangolo, P.; Resnati, G. ACS Symp. Ser. 2000, 746, 239-254.
- 14. (a) Hendrickson, J. B.; Judelson, D. A.; Chancellor, T. Synthesis 1984, 320–322; (b) Tordeux, M.; Langlois, B. R.; Wakselman, C. J. Org. Chem. 1989, 54, 2452–2453.
- 15. Umemoto, T. Chem. Rev. 1996, 96, 1757–1777.